

Mapping the flow of light in a photonic chip using Ultrafast Photomodulation Spectroscopy (UPMS)

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Part I:

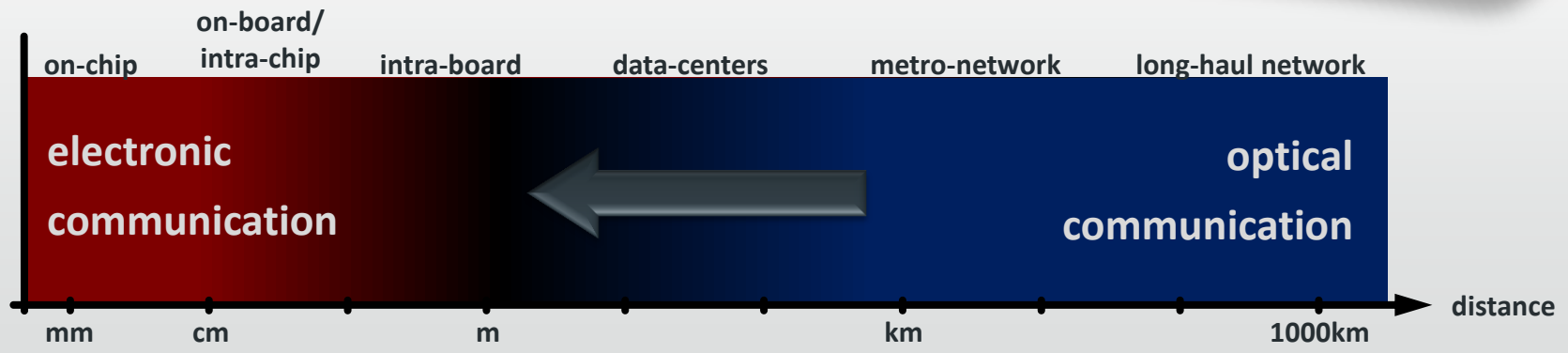
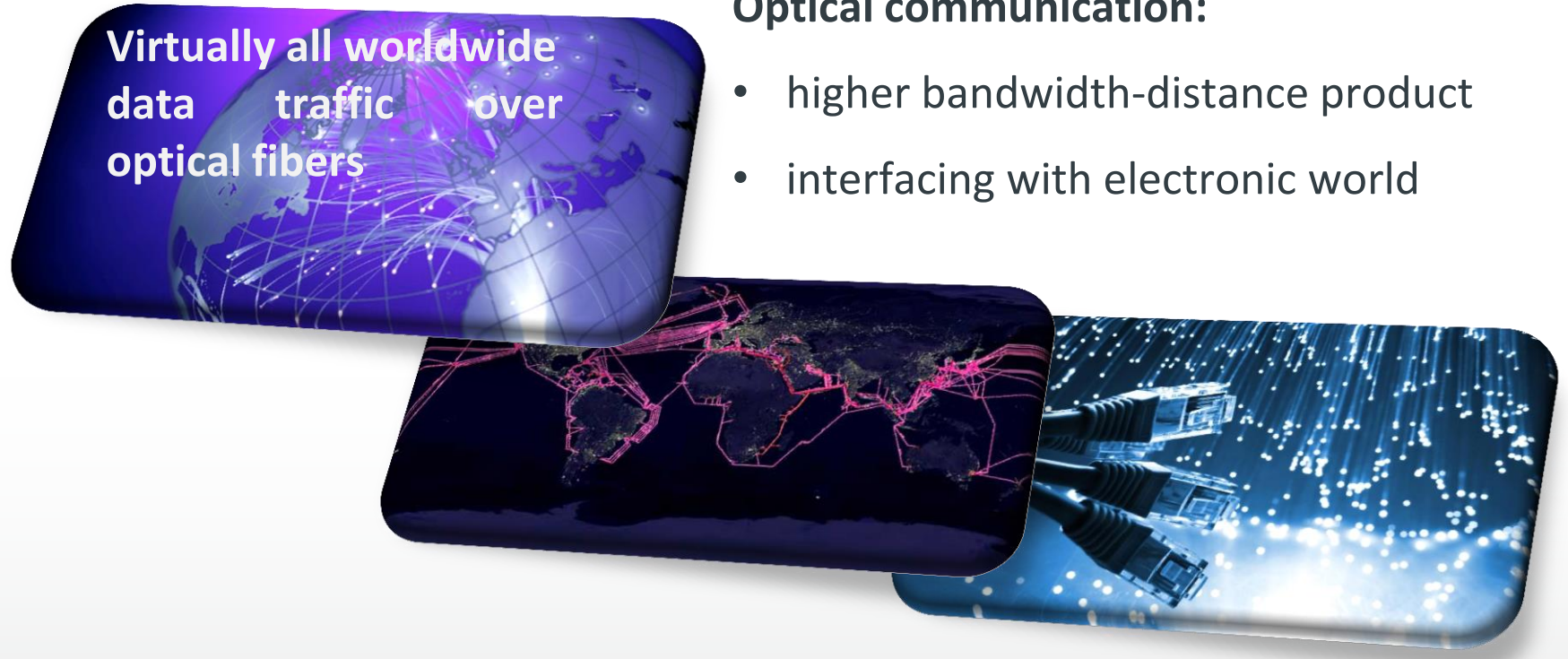
Why do we need
to map the flow of light
in a photonic chip?

Optical vs electronic data communication

Virtually all worldwide data traffic over optical fibers

Optical communication:

- higher bandwidth-distance product
- interfacing with electronic world



Consequences for integrated optics:

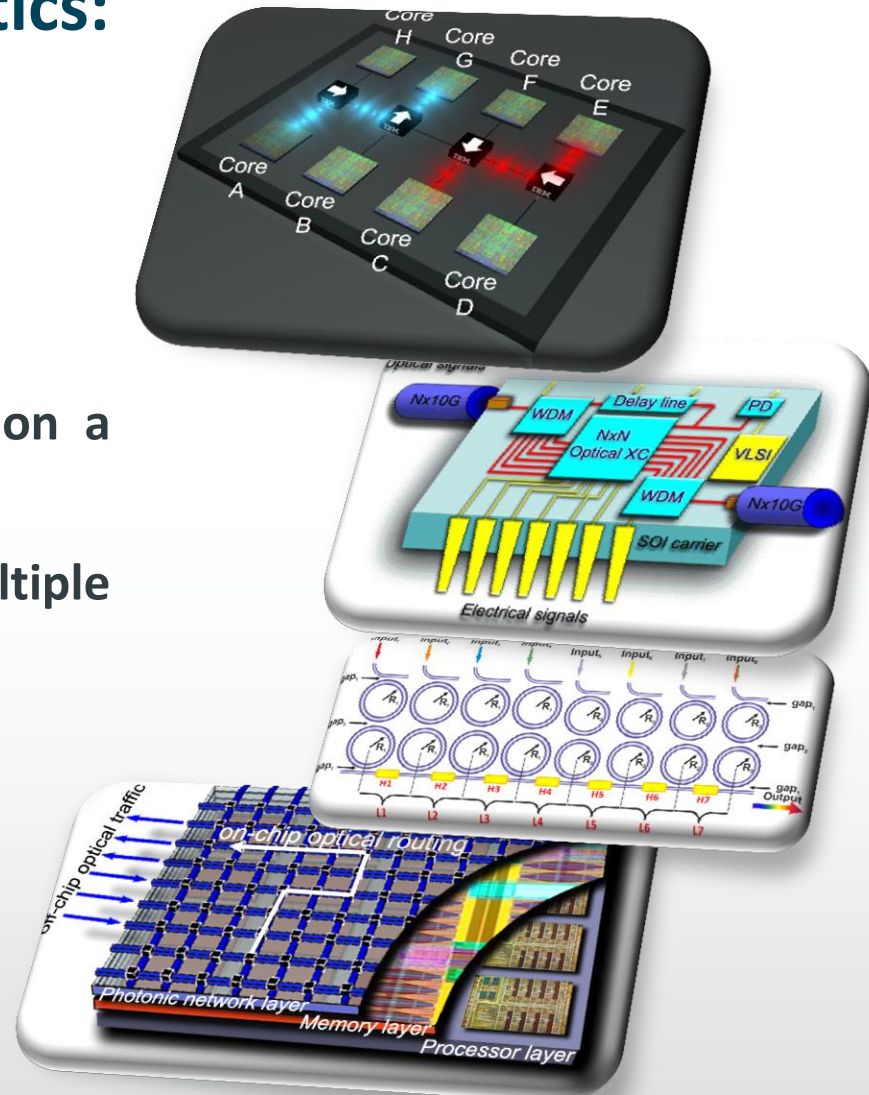
- all-optical signal processing
- on-chip optical data communication

➔ the photonic chip

- integration of more functions on a single chip
- complex designs with multiple subsequent elements

Silicon on insulator (SOI) as most promising platform:

- compatible with electronics world
- mature technology platform & mass production

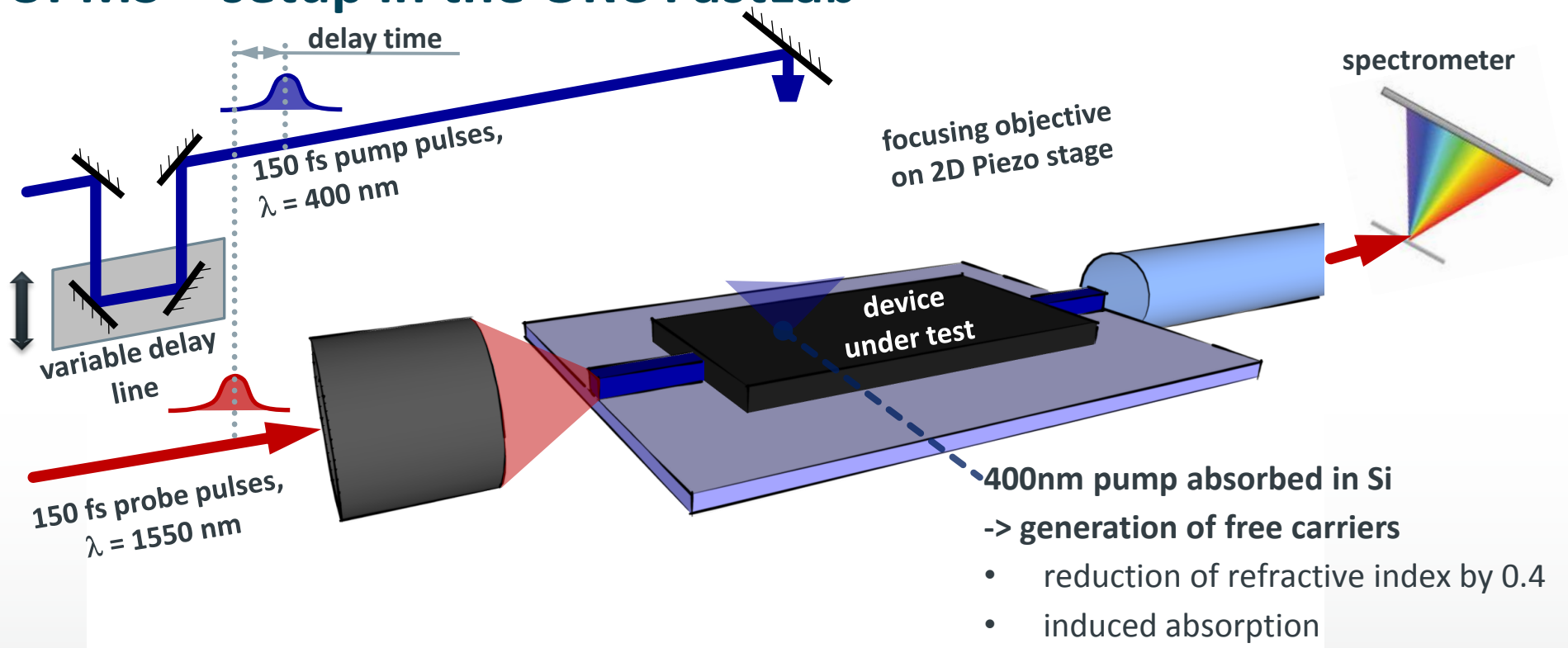


New characterization tools for complex chips are needed!

Part II:

How do we
map the flow of light
in a photonic chip?

UPMS – setup in the ORC FastLab



• reduction of refractive index by 0.4
• induced absorption
localized perturbation in the photonic circuit

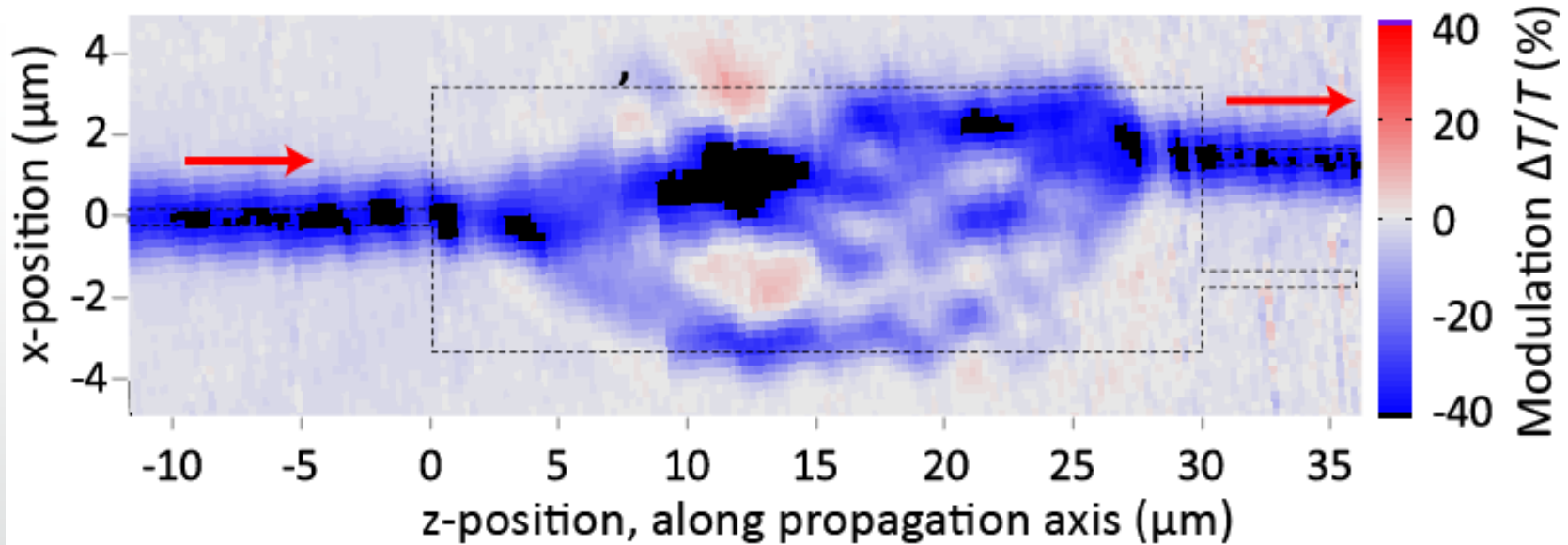
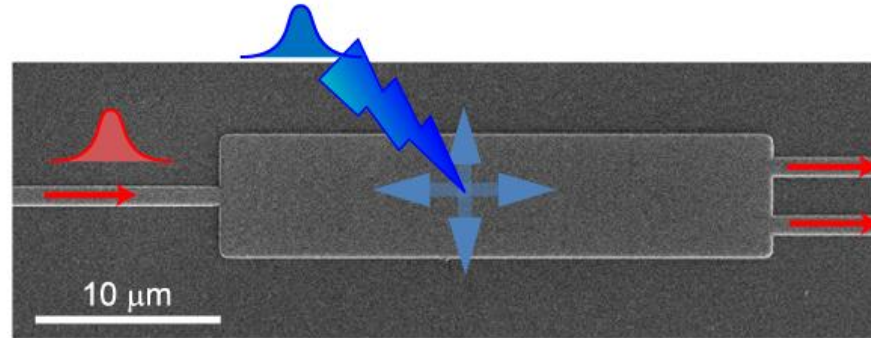
- addressing individual elements by pumping a small spot from top
- access to the time response of elements
- full spectrum for each measured point

In a nutshell, UPMS finds how much light of which wavelength is at a given time at the investigated position

Spatial mapping – multimode interference device

MMI

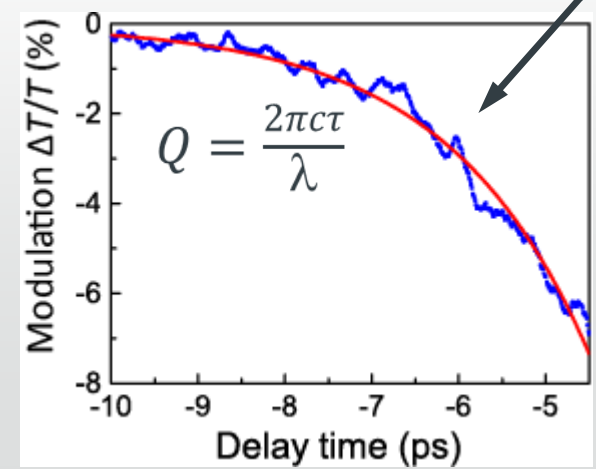
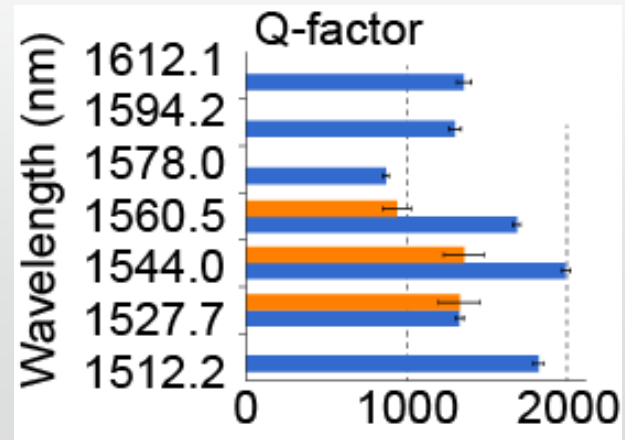
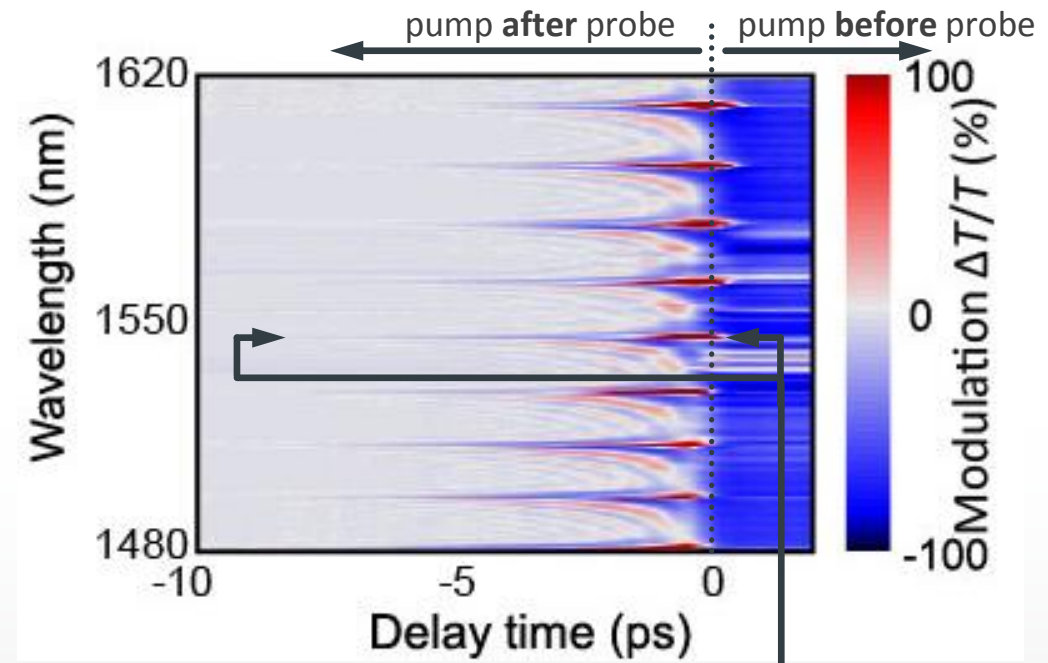
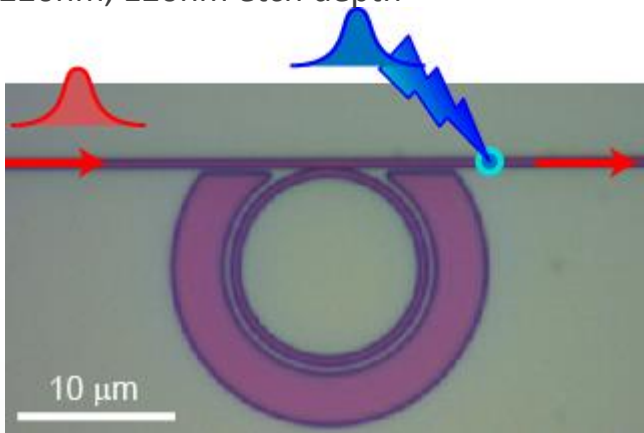
6.5 μm x 29.5 μm
wire waveguides (1000nm x 220nm)
 $\lambda = 1556.5$ nm



Time-domain measurements: ring resonator

ring resonator

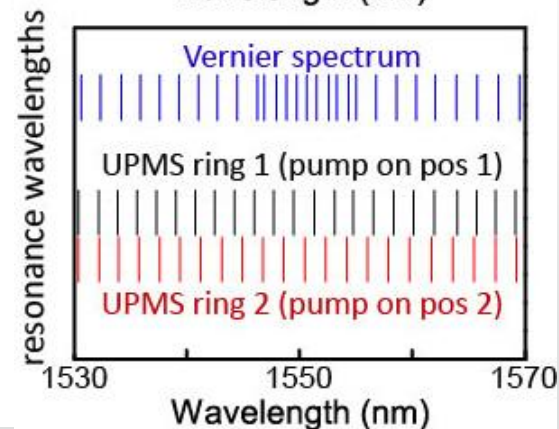
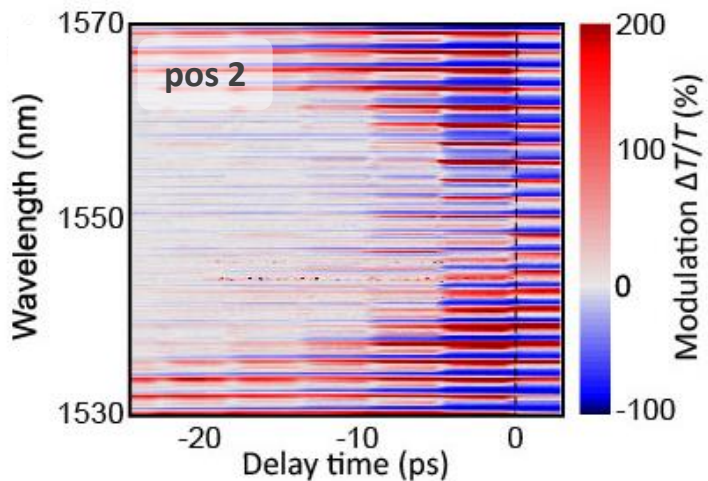
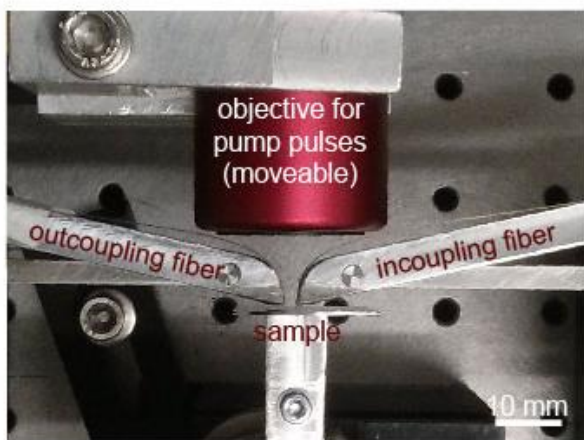
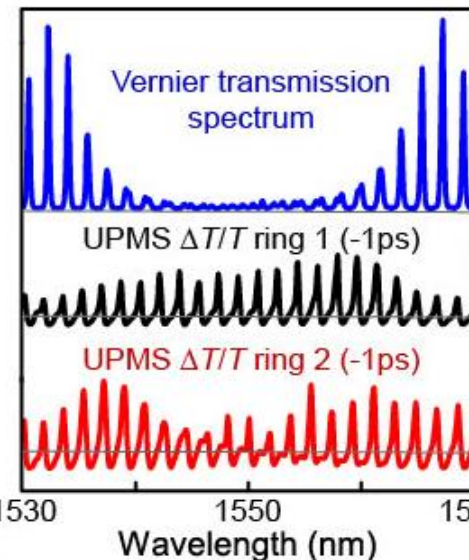
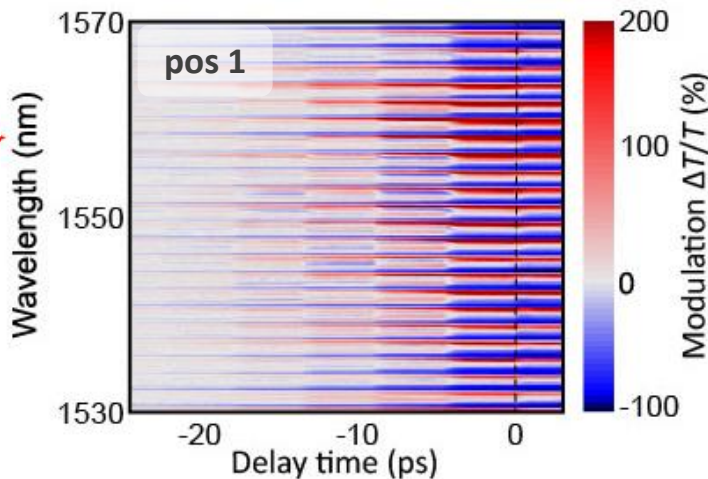
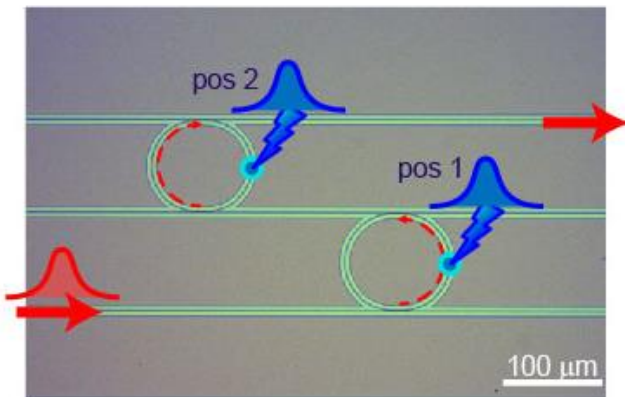
d=12μm, rib waveguides
450nm x 220nm, 120nm etch depth



Time-domain measurements: Vernier resonators

racetrack resonators

$d=94\mu\text{m}$ & $104\mu\text{m}$, rib waveguides
450nm x 400nm, 180nm etch depth



Summary

Mapping the flow of light by

Ultrafast Photomodulation Spectroscopy UPMS:

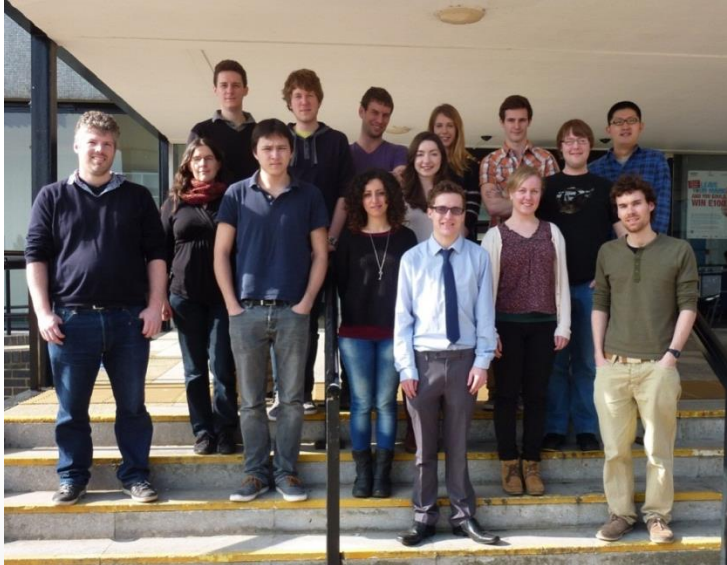
- spatial domain: sub- μm spatial resolution
- time domain: ultrafast time resolution
- frequency domain: spectrally resolved result
- large effect on silicon $\Delta n_{Si} = -0.4 + 0.06i$

Characterization of any SOI waveguide device

- transparent claddings
- end face & grating coupling
- particularly for complex designs,
where transmission function of single elements is obscured
- no test structures needed

Acknowledgements

Otto Muskens & group



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Ben Mills
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Vittorio Passaro
David Thomson
Frederic Gardes
Youfang Hu

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EPSRC

Engineering and Physical Sciences
Research Council

UNIVERSITY OF
Southampton

Do you want to know more?

R. Bruck et al.,

“Device-level characterization of the flow of light in integrated photonic circuits using ultrafast photomodulation spectroscopy”,
Nature Photonics (2014), accepted

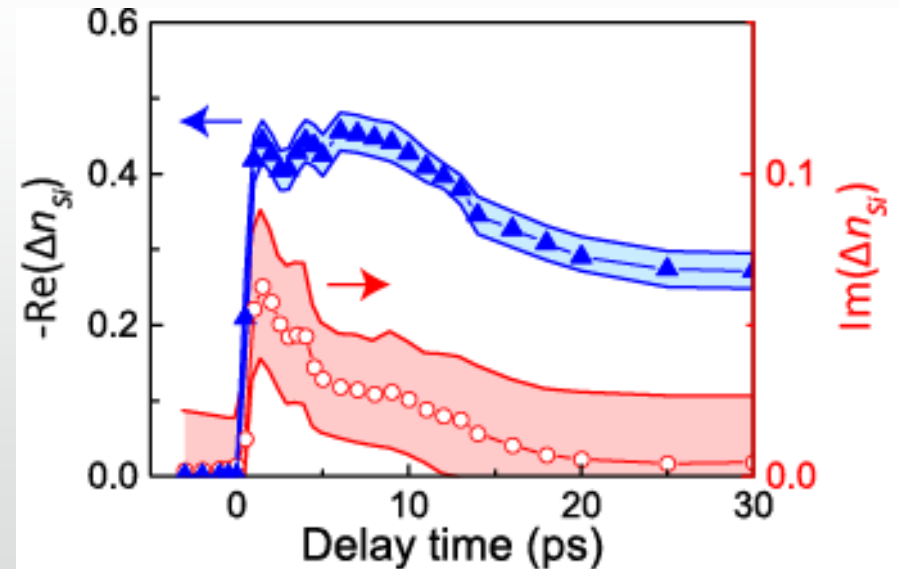
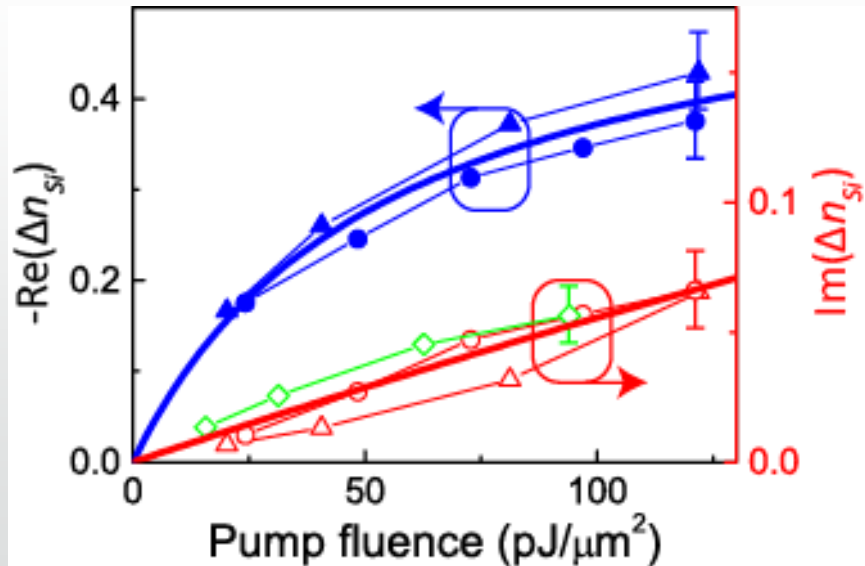
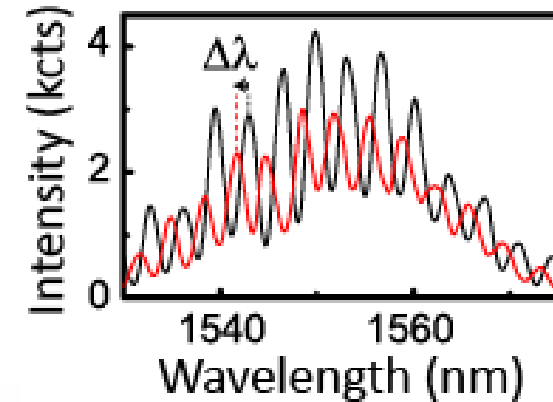
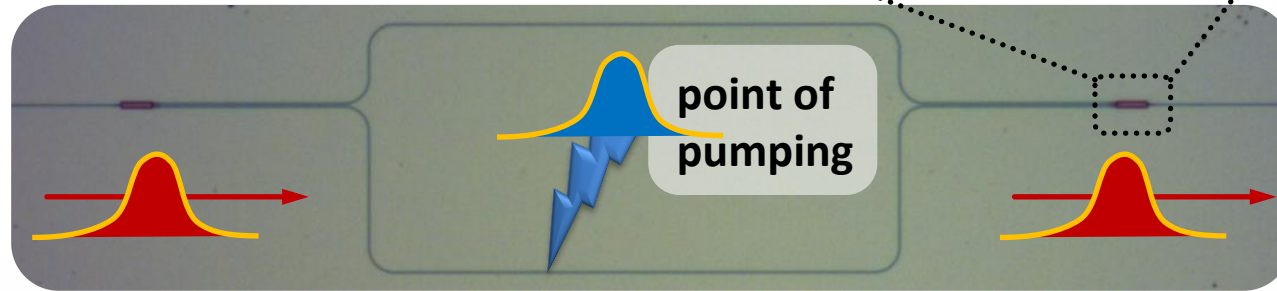
or

<http://arxiv.org/abs/1406.1931>

Effect of the pump pulses on silicon

asymmetric MZI

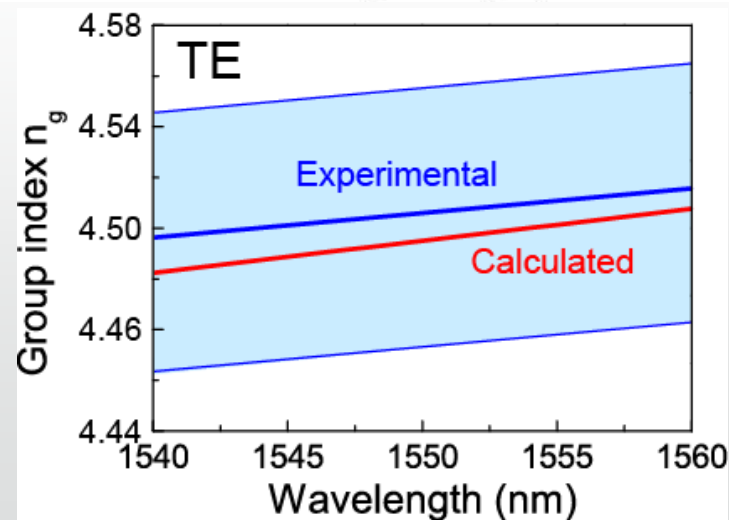
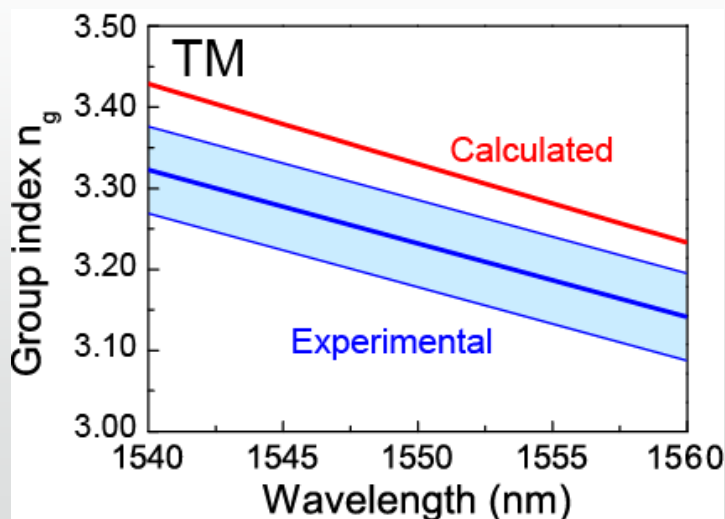
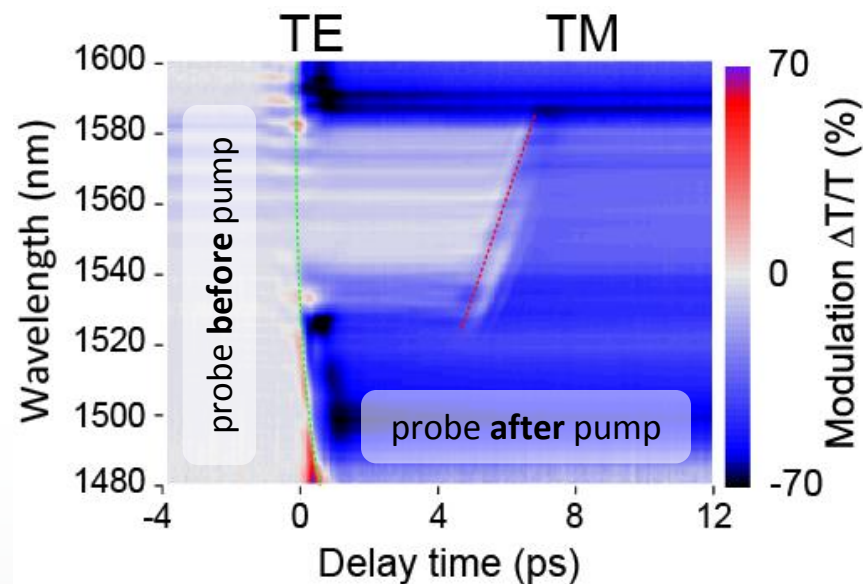
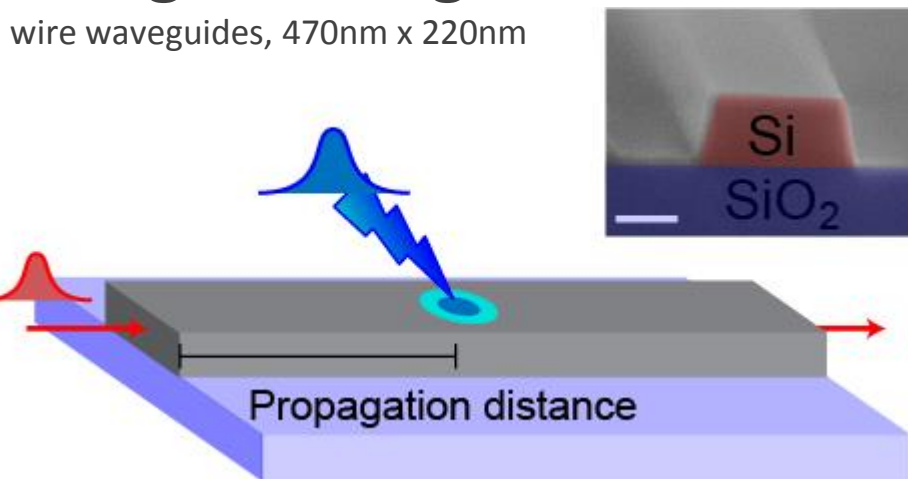
$\Delta L = 180\mu\text{m}$, rib waveguides
450nm x 220nm, 120nm etch depth



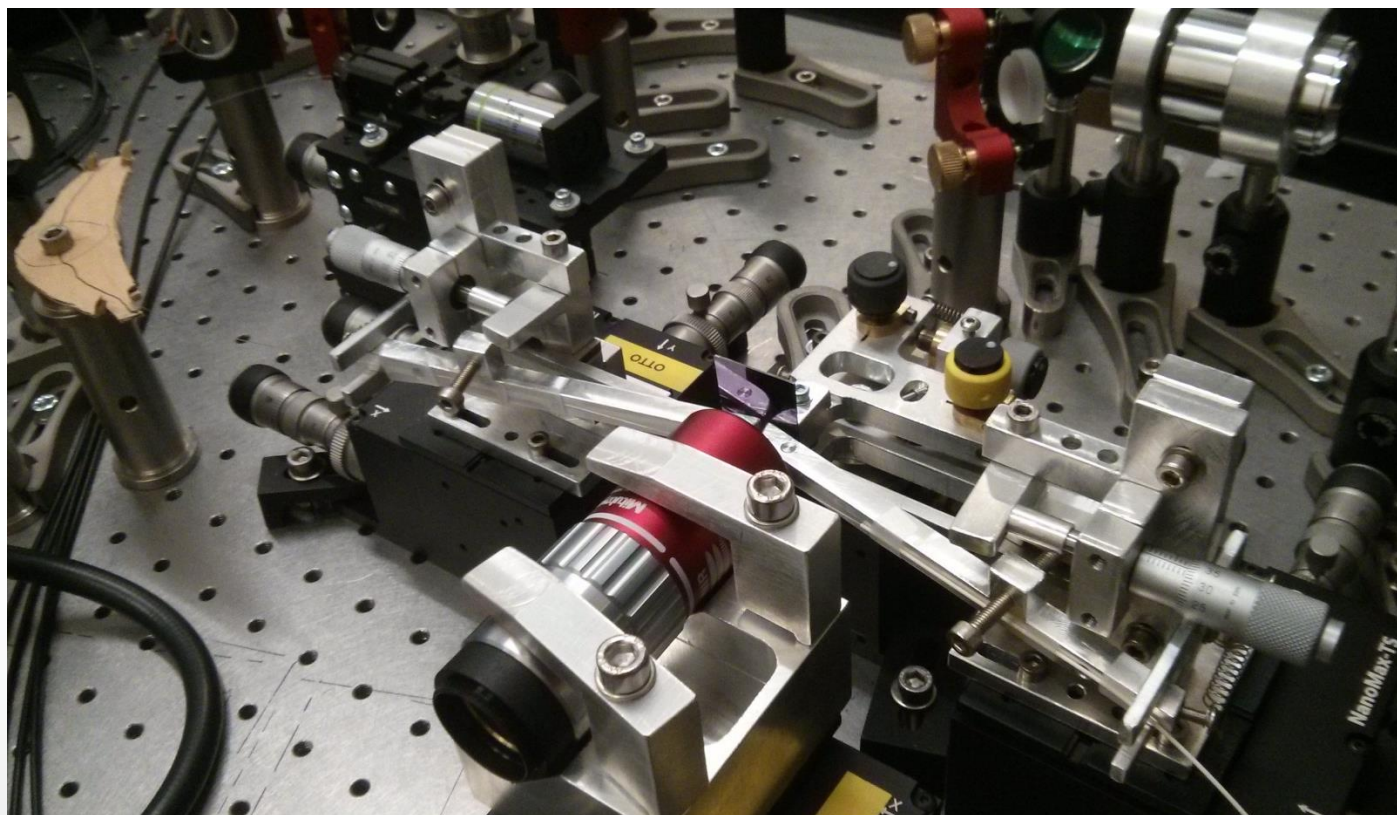
Time-domain measurements: group index

straight waveguide

wire waveguides, 470nm x 220nm



UPMS – upgrade of FastLab setup



- Upgrade for grating couplers
- New Piezo stage, 29mm travel in 3D (mid of October)